Notice of References Cited

Application No. 08/876,812

Applicant(s)

Examiner

Quang N. Phan

Group Art Unit 1641

Douglas et al

Page 1 of 2

| 2 11 | DAT | TENT | DO | | BAEN | ITC |
|------|-----|-------------|-----|----|-------|-----|
| U.S. | PA: | ENI | ียบ | CU | IVIEN | 115 |

| L | | DOCUMENT NO. | DATE | NAME | CLASS | SUBCLASS |
|---|--------|---------------------|----------|--------------------|-------|----------|
| | A | 5,708,247 | 1/13/98 | McAleer et al. | 204 | 403 |
| L | В | 5,437,999 / | 8/1/95 | Diebold et al. | 435 | 288 |
| | С | 4,226,898 | 10/7/80 | Ovshinsky et al. | 427 | 39 |
| L | D | 4,217,374 | 8/12/80 | Ovshinsky et al. | 427 | 39 |
| | E | 4,178,415 / | 12/11/79 | Ovshinsky et al. | 428 | 446 |
| L | F | 5,391,250 🗸 | 2/21/95 | Cheney, II et al. | 156 | 268 |
| | G H | 5,126,034 | 6/30/92 | Carter et al. | 204 | 403 |
| L | | 5,580,794 / 12/3/ | | Allen | 436 | 169 |
| | | 5,277,870 / 1/11/94 | | Fuller et al. | 422 | 82.05 |
| | J | 5,344,754 | 9/6/94 | Zweig | 435 | 4 |
| | ĸ | 5,312,762 | 5/17/94 | Guiseppi-Elie | 436 | 149 |
| | L | 5,174,963 📝 | 12/29/92 | Fuller et al. | 422 | 82.05 |
| | М | 5,137,827F | 8/11/92 | Mroczkowski et al. | | 288 |

FOREIGN PATENT DOCUMENTS

| | DOCUMENT NO. | DATE | COUNTRY | NAME | CLASS | SUBCLASS |
|---|----------------|---------|---------|----------------|-------|----------|
| N | 0 351 891 A1 | 1/24/90 | EPO | Hill et al. | G01N | 27/30 |
| 0 | 0 255 291 B1 🔏 | 2/3/88 | EPO | Birch et al. | G01N | 27/42 |
| Р | WO 91/084/4 / | 6/13/91 | WIPO | Girault et al. | G01N | 27/30 |
| a | 0 470 649 A2 🗸 | 2/12/92 | EPO | Birch et al. | C12Q | 1/26 |
| R | 0 351 891 B1 | 9/29/93 | EPO | Hill et al. | G01N | 27/30 |
| s | 0 213 825 A2 / | 3/11/87 | · EPO | Hafeman et al. | G01N | 27/22 |
| Т | 0 593 096 A2 / | 4/20/94 | EPO | Carter et al. | G01N | 27/327 |

NON-PATENT DOCUMENTS

| | DOCUMENT (Including Author, Title, Source, and Pertinent Pages) | DATE |
|---|---|------|
| U | Yokoyama, Kenji. Amperometric Glucose Sensor Using Silicon Oxide Deposited Gold Electrodes; Electroanalysis, 3, 1991. pp. 469-475 | |
| v | | |
| w | | |
| x | | |

| • | Nation of D. C. | O | Application No. Applicant(s) 08/876,812 Douglas et al | | | | |
|----------|-----------------|--------------------------|--|--------|---|-------|----------|
| | Notice of Refe | Examiner Quang N. P. | Examiner Group Art Quang N. Phan 164 | | | | |
| | | U.S | S. PATENT DOCUMENTS | | | | |
| | DOCUMENT NO. | DATE | NAME | | | CLASS | SUBCLASS |
| А | 5,143,694 | 9/1/92 | Schafer e | t al. | | 422 | 65 |
| В | 5,413,690 | 5/9/95 | Kost et | al. | | 204 | 403 |
| С | 4,994,167 | 2/19/91 | Shults et | al. | | 204 | 403 |
| D | 5,296,194 | 3/22/94 | lgarash | ni | | 422 | 82.05 |
| E | 3,983,076 | 9/28/76 | Rockstad e | et al. | | 252 | 518 |
| F | | | | | | | |
| G | | | | | | | |
| н | | | | | | | , |
| ı | | | | | | | |
| ı | | | | | | | |
| к | | | | | | | |
| L | | | | | | | |
| м | | | | ··· | | | • |
| | | FORE | IGN PATENT DOCUMENTS | | - · · · · · · · · · · · · · · · · · · · | | |
| | DOCUMENT NO. | DATE | COUNTRY | NAME | | CLASS | SUBCLASS |
| N | | | | | | | |
| 0 | | | | | | | |
| Р | | | | | | | |
| Q | | | | | | | |
| R | | | · | | | | |
| s | | | | | | | |
| T | | | | | | | |
| | | Not | N-PATENT DOCUMENTS | | | | |
| <u> </u> | | DOCUMENT (Including Auth | nor, Title, Source, and Pertinent Pag | es) | | | DATE |
| U | · | | | | | | |
| v | | | | | | | |
| w | | | | | | | |
| x | <u> </u> | | | | | | |